

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

<b>AMENDMENT</b>		ATTORNEY DOCKET NO. <b>70020.0066USWO</b>	
		U.S. APPLICATION SERIAL NO. <b>10/543,092</b>	CONF. NO. <b>4088</b>
		35 U.S.C. 371 DATE <b>July 22, 2005</b>	
INVENTOR(S) <b>Takashi MIYAMATSU et al.</b>	EXAMINER <b>John S Y CHU</b>		GROUP ART UNIT <b>1752</b>
TITLE OF APPLICATION <b>SULFONIUM SALT COMPOUND, PHOTOACID GENERATOR, AND POSITIVE-TONE RADIATION-SENSITIVE RESIN COMPOSITION</b>			

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed June 26, 2007, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims that begins on page 2 of this paper.

**Remarks** begin on page 8 of this paper.